IN THE CLAIMS

1-41. (canceled)

- 42. (previously presented) A process for the production of a durable photocatalytically active coated glass which comprises depositing on the surface of a glass substrate a photocatalytically active titanium oxide layer having a thickness of less than 40 nm by contacting the surface of the substrate, which is at a temperature in the range 645°C to 720°C, with a fluid mixture containing a source of titanium.
- 43. (previously presented) A process as claimed in claim 42 wherein the substrate is at a temperature in the range 670°C to 720°C.
- 44. (previously presented) A process as claimed in claim 42 wherein the fluid mixture is a gaseous mixture comprising titanium tetraalkoxide as the source of titanium.
- 45. (previously presented) A process as claimed in claim 42 wherein the fluid mixture is a gaseous mixture comprising titanium tetraethoxide as the source of titanium.
- 46. (previously presented) A process as claimed in claim 42 wherein the fluid mixture comprises titanium chloride as the source of titanium and an ester other than a methyl ester.
- 47. (previously presented) A process for the production of a photocatalytically active coated substrate which comprises depositing a titanium oxide coating having a thickness of less than 40 nm on a substrate by contacting a surface of the substrate with a fluid mixture comprising titanium chloride and an ester other than a methyl ester.
- 48. (previously presented) A process as claimed in claim 47 wherein the surface of the substrate is contacted with the fluid mixture when the substrate is at a temperature in the range 600°C to 750°C.

- 49. (previously presented) A process as claimed in claim 47 wherein the ester comprises an alkyl ester having an alkyl group with a β hydrogen.
- 50. (previously presented) A process as claimed in claim 47 wherein the ester comprises a carboxylate ester.
- 51. (previously presented) A process as claimed in claim 47 wherein the ester is an alkyl ester having a C₂ to C₄ alkyl group.
- 52. (previously presented) A process as claimed in claim 51 wherein the ester comprises an ethyl ester.
- 53. (previously presented) A process as claimed in claim 52 wherein the ester comprises ethyl acetate.
- 54. (previously presented) A process as claimed in claims 47 wherein the ester is the only source of oxygen in the fluid mixture.
- 55. (currently amended) A process as claimed in claim [[1]] 42 wherein the fluid mixture is a gaseous mixture.
- 56. (currently amended) A process as claimed in claim [[1]] 42 wherein the process is performed on-line during the float glass production process and the substrate is a glass ribbon.
- 57. (previously presented) A process as claimed in claim 56 wherein the process is performed in the float bath.
- 58. (currently amended) A process as claimed in claim [[1]] 42 wherein the process is performed at substantially atmospheric pressure.